

Optimal Experiment Design for a Wafer Stage

Citation for published version (APA):

Dirkx, N., van de Wijdeven, J., & Oomen, T. (2020). Optimal Experiment Design for a Wafer Stage: A Sequential Relaxation Approach. In R. Carloni, B. Jayawardhana, & E. Lefeber (Eds.), *39th Benelux Meeting on Systems and Control: Book of Abstracts* (pp. 98). University of Groningen.

Document status and date:

Published: 01/01/2020

Document Version:

Publisher's PDF, also known as Version of Record (includes final page, issue and volume numbers)

Please check the document version of this publication:

- A submitted manuscript is the version of the article upon submission and before peer-review. There can be important differences between the submitted version and the official published version of record. People interested in the research are advised to contact the author for the final version of the publication, or visit the DOI to the publisher's website.
- The final author version and the galley proof are versions of the publication after peer review.
- The final published version features the final layout of the paper including the volume, issue and page numbers.

[Link to publication](#)

General rights

Copyright and moral rights for the publications made accessible in the public portal are retained by the authors and/or other copyright owners and it is a condition of accessing publications that users recognise and abide by the legal requirements associated with these rights.

- Users may download and print one copy of any publication from the public portal for the purpose of private study or research.
- You may not further distribute the material or use it for any profit-making activity or commercial gain
- You may freely distribute the URL identifying the publication in the public portal.

If the publication is distributed under the terms of Article 25fa of the Dutch Copyright Act, indicated by the "Taverne" license above, please follow below link for the End User Agreement:

www.tue.nl/taverne

Take down policy

If you believe that this document breaches copyright please contact us at:

openaccess@tue.nl

providing details and we will investigate your claim.

Optimal Experiment Design for a Wafer Stage: A Sequential Relaxation Approach

Nic Dirkx^{1,2}, Jeroen van de Wijdeven¹, Tom Oomen²

¹ *ASML Research Mechatronics & Control, Veldhoven, The Netherlands*

² *Eindhoven University of Technology, Department of Mechanical Engineering, Control Systems Technology, The Netherlands*

1 Background

Ever-increasing performance requirements for high-precision positioning systems such as wafer scanners requires the availability of accurate models [1]. Frequency Response Function (FRF) identification from experimental data is considered a fast, inexpensive, and accurate method to obtain such models [2].

2 Problem

The choice of input signal determines the quality of the identified FRF, which motivates the employment of Optimal Experiment Design (OED) strategies. OED involves the optimization of the inputs to maximize the model accuracy within the available resources [3]. For Multiple Inputs Multiple Outputs (MIMO) systems, OED does not only require appropriate design of the magnitudes of the input signals, but also their directions. Furthermore, the design must address the specific constraints that are relevant for the considered system. For wafer stages, these constraints are typically related to specific elements of the systems, e.g., a power limitation for a specific actuator or a limitation of a local displacement.

The aim of this research is to develop OED methods that explicitly address directionality in excitation design within element-wise power constraints.

3 Approach

The OED problem is formulated as the constrained minimization of a cost function $\mathcal{J}(\Phi_w)$ related to the FRF accuracy over the input spectrum Φ_w :

$$\begin{aligned} & \text{minimize} && \mathcal{J}(\Phi_w) \\ & \text{subject to} && g(\Phi_w) \leq 0 \\ & && \text{rank}(\Phi_w) = 1. \end{aligned} \quad (1)$$

Here, the combination of $g(\cdot)$ and the rank constraint function forms the set of element-wise power constraints. Due to the rank constraint, problem (1) is non-convex and hard to solve in most cases.

A Sequential Relaxation (SR) algorithm is proposed that replaces the rank constraint in (1) by an approximate convex function, and then solves the resulting sequence of convex optimization problems. The solution of the SR algorithm is guaranteed to converge to a local minimum of the original non-convex problem (1).

¹E-mail: nic.dirkx@asm1.com

4 Results

The developed method is experimentally tested for the identification of the 4×4 dynamics of a wafer stage, see Fig. 1. The system is subject to element-wise output power constraints. Three different excitation designs are compared:

- R1) Preliminary design, using a uniform excitation power distribution.
- R2) Traditional optimized single input design approach with optimized excitation magnitude, but non-optimized directions.
- R3) Optimal multivariable design using the SR algorithm, with optimized magnitudes and directions.

Fig. 1 shows entry (1,1) of the resulting FRFs, including 95% confidence regions (shades) and standard deviations (dashed). The multivariable design (R3) achieves a factor 2 lower standard deviation compared to the traditional approach (R2) by exploiting directionality in the design.

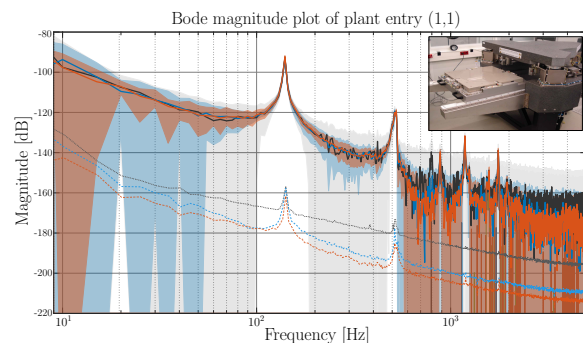


Figure 1: Identified FRFs using design R1 (black), R2 (blue), and R3 (red). Top right: wafer stage setup.

5 Ongoing work

Ongoing research includes development of methods for:

- dealing with peak amplitude constraints
- standard plant identification, including identification of unmeasurable performance variables.

References

- [1] T. Oomen, "Advanced Motion Control for Precision Mechatronics: Control, Identification, and Learning of Complex Systems," *IEEJ Journal of Industry Applications*, 7, 127-140. 2018.
- [2] R. Pintelon, J. Schoukens, "System identification: a frequency domain approach," *J. Wiley*, 2012
- [3] H. Hjalmarsson, "From experiment design to closed-loop control," *Automatica*, 41(3), 2005